물질의 광학적 두께에 따른 EMP-simulation을 통한 광특성 대조 장강재, 장건익, 이남일*, 정재일*, 임광수* 충북대학교 신소재공학과, CQV Co. Ltd*

The Comparison of Optical Properties with

Different Optical Thickness of Materials by EMP-simulation

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Abstract: ZnS/Na₃AlF₆/ZnS/Cu multi-layered thin film were simulated by EMP. EMP is a comprehensive software package for the design and analysis of optical thin film. ZnS and Na₃AlF₆ was selected as a high refractive index material and low refractive index material And Cu was selected as mid reflective material. Optical properties including color effect were systematically studied in terms of different low refractive index materials thickness. Na₃AlF₆ were changed 0.25, 0.5, 0.75, 1.0 λ . The thin film showed 0.25 λ : blue, purple / 0.5 λ : yellow / 0.75 λ : blue, purple, red / 1.0 λ : yellow, green, blue, purple. It was becaused by different optical thickness of Na₃AlF₆. The maximum of optical interference by refractive layer.